Replica-molded electro-optic polymer Mach–Zehnder modulator

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(Received 4 March 2004; accepted 29 June 2004)

A Mach–Zehnder electro-optic polymer amplitude modulator is fabricated by a simple and high-throughput soft-stamp replica-molding technique. The modulator structure incorporates the highly nonlinear and stable chromophore, AJL8, doped in amorphous polycarbonate. Single-arm phase-retardation results in a halfwave voltage \( V_{1/2} \) of 8.4 V at 1600 nm. The on/off extinction ratio is better than 19 dB, resulting from precise Y-branch power splitters and good waveguide uniformity. These results indicate that the simple fabrication process allows for good optical performance from high-fidelity replicas of the original master devices. © 2004 American Institute of Physics. [DOI: 10.1063/1.1787944]

Organic nonlinear optical materials have been the subject of significant recent technological advances with the aim of commercial deployment, especially for telecommunications applications. Polymers for integrated optical circuits exhibit several advantageous features. The raw materials are lower cost than their crystalline and semiconductor counterparts and offer more flexible fabrication methods. Electro-optic polymers have low material dispersion, and thus low velocity mismatch between optical signals and microwave optic polymers have low material dispersion, and thus low velocity mismatch between optical signals and microwave optic polymers exhibit a very high nonlinearity, allowing for modulators with switching voltages of less than 1 V. Recent advanced chromophore design has resulted in the development of highly nonlinear chromophores with good thermal- and photo-stability. Shown in Fig. 1 is the chemical structure of one such chromophore, referred to as AJL8. Films of AJL8 doped in an amorphous polycarbonate matrix exhibit a very high \( r_{33} \) value of 94 pm/V at 1300 nm. The onset degradation temperature was found to be 220 °C and around 80% of its original \( r_{33} \) value maintained very constantly for more than 500 h at 85 °C.

Since electro-optic polymers are not generally photocurable themselves, fabrication of polymer modulators has been mostly limited to traditional semiconductor etching techniques such as reactive ion etching. An alternative fabrication technique that takes advantage of the plastic nature of electro-optic polymers is soft-stamp replica-molding lithography. The main benefits of this technique are the simple and high-throughput fabrication (single-step structure formation), the low fabrication set-up costs, and the ability to replicate nanometer-scale structures over many square centimeters. In this technique, waveguide structures are formed by the molding of the core polymer using a soft stamp. Materials fabricated by this method can be either photo-curable, due to the transparency of the stamp material to ultraviolet light, or solidified by solvent evaporation, made possible by the permeability of the stamp material to common polymer solvents. Previously, this technique has been employed to make optical couplers and polymer distributed feedback and distributed Bragg reflector lasers for use in the visible regime. For infrared applications, this technique has been applied to optical interconnects and microring resonator optical filters. In this letter, we demonstrate the use of the replica molding technique for the fabrication of electro-optic polymer amplitude modulators.

The first portion in the replica molding process, shown in Figs. 2(a)–2(c), is the production of a mechanically flexible poly(dimethylsiloxane) (PDMS) stamp. Because of the low surface energy of the elastomer stamp material, the master device to be replicated can be made of many commonly used resist, glass, or semiconductor materials. Ultraviolet lithography of photoresist is frequently used for patterning the master device. For smaller and higher resolution structures, electron beam lithography can be used. Liquid PDMS is poured atop the master structure and cured for 2 h at 80 °C. The cured PDMS stamp is peeled from the master device and diced to the required size. Since the curing and peeling of the PDMS stamp does not alter the original master, the master can be used to make additional stamps by repeating the preceding steps.

The replication procedure is shown in Figs. 2(d)–2(f). Similar to the case of the master device, the low surface adhesion and the chemical inertness of the PDMS allow virtually any polymer material in many solvents to be used for the replication. A droplet, tens of \( \mu \)L in volume, of the core material is poured atop the replica stamp and cured in the same solvent of the stamp material for 2 h. After curing, the replicated device is peeled from the stamp and diced to the required size. The cured polymer devices show no delamination from the stamp material and exhibit a high degree of uniformity. The replication technique is evaluated using a Mach–Zehnder electro-optic polymer amplitude modulator fabricated as described in the previous section. In the Mach–Zehnder modulator configuration, the phase retardation is adjusted using an electric field applied across the core polymer slab. Since the optical path length difference generated by the phase shifter is proportional to the applied voltage, the output intensity of the modulator changes accordingly. The results are shown in Figs. 3(a)–3(c) and indicate that the 3 dB extinction ratio is better than 19 dB. This corresponds to a halfwave voltage of 8.4 V at 1600 nm.
A master MZI device (a) is patterned by photolithography of SU-8. PDMS is poured on the master device (b), cured, peeled, and diced (c). A drop of electro-optic core solution is placed on the appropriate substrate (d). The PDMS stamp is depressed (e) until the core polymer is cured. The stamp is peeled to reveal the high-fidelity replicated device (f).

The core polymer is composed of the aforementioned AJL8 chromophore as the nonlinear optical dopant in amorphous polycarbonate (APC, Aldrich). APC has been shown to have excellent thermal stability as a polymer host material. The ratio of chromophore to passive polymer was 20 wt% as in Ref. 5. A final solution concentration of 1.6 wt% was achieved by dissolving the solid in dibromomethane, yielding a solution with a moderate evaporation rate appropriate for the replica molding process.

The randomly oriented chromophores dispersed in the APC matrix must be aligned to result in a collective electro-optic effect. By heating the polymer film above its glassy temperature (\(T_g \approx 145^\circ C\) for AJL8/APC) while applying a strong electric field, the dipolar chromophores are aligned. We employ the corona poling method\(^{12}\) with a needle-to-sample separation of 2 cm. The needle tip is biased to approximately 5.6 kV. As the sample is heated to 145°C, the corona current is monitored by measuring the voltage drop across a 10 M\(\Omega\) resistor and is limited to 2 \(\mu\)A in an ambient air environment. The sample is poled for approximately 45 min, and then cooled while keeping the voltage applied. At \(\sim 40^\circ C\), the voltage is turned off and the sample is removed.

To prepare for measurement, the substrate is cleaved and the waveguide end-facets are left unpolished. Laser light at 1600 nm wavelength is fed through a polarizer and input into the MZI through a tapered fiber. The output signal is collected using another fiber and is measured using a photodetector. The voltage is applied to the MZI using either a voltage source or a function generator. The entire setup is controlled by GPIB.

The measurement results are shown in Fig. 4. Voltages ranging from \(-40\) to \(+40\) V are sequentially applied in 0.25 V increments while monitoring the photodetector output signal. The measurement was also confirmed using a 1 kHz triangle wave and an oscilloscope. With no applied
The deep extinction of the nulls in the output shown in Fig. 4 are better than 19 dB, indicating that the two arms of the interferometer are of slightly different length. The half-wave voltage \( V_{\pi} \), defined as the voltage required to switch the output from full-on to full-off, is found to be 8.4 V. This value is within a factor of 2 of commercial devices, and several means can be employed to further reduce this value. First, thinning of the cladding layers would proportionally reduce \( V_{\pi} \). Second, the voltage was applied to only one arm of the MZI, not to both arms in a push–pull fashion, which would result in a factor of 2 reduction in \( V_{\pi} \). Finally, optimization of the poling efficiency is necessary to further reduce \( V_{\pi} \). The total insertion loss was not measured since the waveguide end-facets were left unpolished and were not mode-matched to the input/output fibers.

While the halfwave voltage is indicative of the polymer nonlinearity and the electrode configuration, the on/off extinction ratio of the modulator signifies the quality and precision of the fabrication. In the MZI structure, light interferes after having traveled different optical path lengths and the degree of destructive interference depends on the quality of both the Y-junction splitter and combiner, and on any differential loss in the arms of the MZI. The extinction ratios of the nulls in the output shown in Fig. 4 are better than 19 dB, similar to recent reports using traditional electro-optic polymer fabrication techniques. The deep extinction of the nulls for the replica molded MZI suggests that the Y junctions are of precise 3 dB splitting ratio and that there is very little differential loss in the interferometer arms. This demonstrates the accuracy of the replication process enabling high-resolution features of the Y junction to be reproduced in the replica. The achieved low differential loss indicates that the replica molding process produces a low number of waveguide defects and good waveguide uniformity over many square centimeters.

In summary, a Mach–Zehnder electro-optic polymer modulator was fabricated by soft-stamp replica-molding. The core polymer incorporated state-of-the-art nonlinear optical chromophores that are highly nonlinear and show good thermal- and photo-stability. The resultant device was measured with 1600 nm incident light to have a halfwave voltage of 8.4 V and an extinction ratio better than 19 dB. These results establish that the replica molding process has the potential to meet the demanding requirements of high-resolution necessary for inexpensive mass production of electro-optic polymer modulators.

This work was financed in part by National Science Foundation and The Defense Advanced Research Program Agency. The authors acknowledge helpful discussions with John Choi, Will Green, Dr. Reg Lee, Joyce Poon, and Dr. Jacob Scheuer. We also thank Dr. Mark Adams and Professor Axel Scherer for photo-mask fabrication.

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